# **PRODUCT MANUAL**

IonPac® TRACE METAL CONCENTRATOR (TMC-1) COLUMN

> Now sold under the Thermo Scientific brand





IC I HPLC | MS | EXTRACTION | PROCESS | AUTOMATION

#### **PRODUCT MANUAL**

#### for the

### IONPAC® TRACE METAL CONCENTRATOR COLUMN (TMC-1) (P/N 049000)

© DIONEX Corporation, 2004

Document No. 034255 Revision 06 18 November 2004

## **TABLE OF CONTENTS**

SECTION 1 - INTRODUCTION			
SECTI	ON 2 - OPERATION	4	
2.1	Chemicals Required	4	
2.2	Solutions Required	4	
2.3	Concentration Methods	4	
SECTION 3 - TROUBLESHOOTING GUIDE			
3.1	High Back Pressure from a Contaminated Inlet Bed Support	5	
3.2	High Background, or Noise	5	
3.3	Poor Peak Shape	6	

#### **SECTION 1 - INTRODUCTION**

The Trace Metal Concentrator Column (TMC-1) is used in Chelation Ion Chromatography. This manual describes the operation of the TMC-1. The following DIONEX Technical Note describes an important application which requires the TMC-1.

Technical Note #	Description
25	Determination of Transition Metals in Complex Matrices by Chelation Ion Chromatography $^{\rm TM}$

The TMC-1 contains a 17- $\mu$ m, fully sulfonated, high capacity cation-exchange resin and has an ion-exchange capacity of 0.3  $\mu$ eq/ column. The TMC-1 has high affinity for alkaline-earth, transition and lanthanide metals. In normal operation, however, Group I and II sample cations are removed in the MetPac CC-1 concentrator column. The TMC-1 is specifically designed for interfacing the MetPac CC-1 Column (P/N 042156) with the IonPac CS5 Analytical Column (P/N 037028), or the IonPac CS5A Anilytical Column (P/N 046100 or 052516).

The operating back pressure of the TMC-1 should be less than 300 psi under normal operating conditions. Typically, the TMC-1 is used in conjunction with the Chelation IC System where the back pressure should not exceed 1,500 psi.





Retention Volume vs Concentration of HNO, for Transition Metals on TMC-1

#### **SECTION 2 - OPERATION**

#### 2.1 Chemicals Required

The chemicals and water required to prepare the reagents and eluents should be of the highest purity available. Use deionized water with a specific resistance of 18.2 megohm-cm. Prepared reagents can be purchased from DIONEX. See Technical Note No. 25 for reagent ordering information and preparation procedures.

#### 2.2 Solutions Required

## Table 1Chelation Concentration Reagents

	1 liter	6 Pack
2 M Nitric Acid	P/N 033442	P/N 033443
2 M Ammonium Acetate	P/N 033440	P/N 033441
0.1 M Ammonium Nitrate	P/N 033444	P/N 033445 (for CIC only)

#### 2.3 Concentration Methods

The TMC-1 is used to interface the MetPac CC-1 with the IonPac CS5 or CS5A Analytical Column when performing Chelation IC (see Technical Note No. 25 for operation of the Chelation IC System).

Install the TMC-1 as indicated in Technical Note No. 25, Figure 3, "Schematic of Chelation IC System 1," or Figure 4, "Schematic of Chelation IC System 2."

The concentrated transition metals can be eluted from the TMC-1 using nitric acid. Use DIONEX 2.0 M Nitric Acid Chelation Concentration Reagent (P/N 033442 or 033443) for the most reliable results. The elution volumes of various transition metals, as a function of nitric acid concentration, is given in Figure 1, "Retention Volume vs. Concentration of HNO<sub>3</sub> for Transition Metals on TMC-1." The TMC-1 is compatible with most acids and bases up to a concentration of 3.0 M.

Due to the relatively high capacity of the TMC-1, it should not be used in place of other cation concentrators such as the IonPacCG2 or CG3.

The recommended cleaning procedure is a 15 minute rinse with 0.02 M oxalic acid at 2.0 mL/min. This cleaning procedure effectively removes both ionic and colloidal metal contamination.

#### **SECTION 3 - TROUBLESHOOTING GUIDE**

The purpose of the Troubleshooting Guide is to help you solve operating problems that may arise while using the Trace Metal Concentrator Column (TMC-1). For more information on problems that originate with the Sample Concentration Module or the Ion Chromatograph, refer to the Troubleshooting Guide in the appropriate operator's manual. If you cannot solve the problem on your own, call the DIONEX Office nearest you (see, "DIONEX Worldwide Offices").

#### 3.1 High Back Pressure from a Contaminated Inlet Bed Support

If the TMC-1 displays high back pressure, the bed support in the column inlet may be contaminated. Follow the instructions below to change the bed support assembly using one of the two spare bed support assemblies included in the ship kit provided with the column.

- a) Disconnect the column from the system.
- b) Carefully unscrew the inlet (top) column end fitting using two open-end wrenches.
- c) Remove the old bed support. Turn the end fitting over and tap it against a benchtop or other hard, flat surface to remove the bed support and seal assembly. If the bed support must be pried out of the end fitting, use a sharp pointed object such as a pair of tweezers, but be careful that you do not scratch the walls of the end fitting. Discard the old assembly.
- d) Place a new bed support assembly in the end fitting. Use the end of the column to carefully start the bed support assembly into the end fitting.

Bed Support Assembly	P/N042955
Seal Washer	P/N042956
Bed Support	P/N053889
End Fitting	P/N042367

e) Screw the end fitting back onto the column. Tighten it fingertight and then using two open-end wrenches, tighten it an additional 1/4 turn (25 in/lb). Tighten further only if leaks are observed.

## **NOTE:** If any of the column packing becomes lodged between the end of the column and the bed support washer assembly, no amount of tightening will seal the column. Make sure that the washer and the end of the column are clean before screwing the end fitting back onto the column.

f) Reconnect the column to the system and resume operation.

#### 3.2 High Background, or Noise

Normally, problems such as high background, noise or baseline instability will not be attributable to the TMC-1. These problems usually originate in either the analytical column or the post-column detection chemistry. Before checking the TMC-1 as the source of system background noise, consult the appropriate troubleshooting sections in the analytical column Product Manual, the Ion Chromatograph Operator's Manual and the detector manual.

If the source of the high background noise is isolated to the TMC-1, then proceed with the following steps:

- a) Make sure that the eluents and regenerant are correctly formulated.
- b) Make sure that the eluents are made from chemicals with the recommended purity (see Section 2, "Operation").
- c) Make sure that deionized water used to prepare the reagents has a specific resistance of 18.2 megohm-cm.

#### 3.3 Poor Peak Shape

In some instances, poor peak shape in Chelation IC may be caused by a contaminated TMC-1. To clean the TMC-1, wash with 2.0 M HNO<sub>3</sub> for 10 minutes at 3.0 mL/min. Following the HNO<sub>3</sub> wash, rinse the column with deionized water for 3 min at 3.0 mL/min. Replace the cleaned column in the Chelation IC System and run through the Chelation IC program once before doing an analytical run.

Corporate Headquarters Dionex Corporation 1228 Titan Way P.O. Box 3603 Sunnyvale, CA 94088-3603 Phone: 408 737-0700 Fax: 408 730-9403

 Salt Lake City

 Technical Center

 1515 West 2200 South, Suite A

 Salt Lake City, UT 84119-1484

 Phone:
 801 972-9292

 Fax:
 801 972-9291

#### LC Packings Netherlands

LC Packings Abberdaan 114 1046 AA Amsterdam The Netherlands Phone: 31-20-683 9768 Fax: 31-20-685 3452

Dionex Softron GmbH

Dornnierstrasse 4 D-82110 Germering Germany Phone: 49 8989 468 0 Fax: 49 8989 468 200 US. Regional Offices Western Region Dionex Corporation 445 Lakeside Drive Sunnyvale, CA 94085 Phone: 408 737-8522 Fax: 408 733-8748

Southwestern Region Dionex Corporation 340 N. Sam Houston Pkwy. East Suite 199 Houston, TX 77060 Phone: 281 847-5652

#### Fax: 281 847-2203 *Central Region*

Dionex Corporation 1010 Executive Court Suite 200 Westmont, IL 60559 Phone: 630 789-3660 Fax: 630 789-3702

#### *Eastern Region* Dionex Corporation 14 E. Stow Road

Suite 100 Marlton, NJ 08053 Phone: 856 596-0600 Fax: 856 596-5358

Southeastern Region Dionex Corporation 1820 Water Place Suite 250 Atlanta, GA 30339 Phone: 770 432-8100 Fax: 770 432-8300 International Subsidiaries Australia Dionex Pty Ltd Unit 31, 2 Chaplin Drive Lane Cove, NSW 2066 Australia Phone: 61 2 9420 5233 Fax: 61 2 9420 5244 Austria Dionex Austria GmbH Laxenburger Strasse 220 A-1230 Wien Austria Phone: 431 616 51 25 431 616 51 25 55 Fax: Belgium Dionex N. V. Draaiboomstraat 6 2160 Wommelgem Belaium Phone: 32 3 353 4294 Fax: 32 3 353 4293 Canada Dionex Canada Ltd. 1540 Cornwall Road Suite 204 Oakville, Ontario L6J 7W5 Canada Phone: 905 844-9650 905 844-6134 Fax: China Dionex China Ltd. Room 2810, Level 28 Metroplaza Tower 2 No. 223 Hing Fong Road Kwai Chung, N.T. Hong Kong China Phone: 852 2428 3282 852 2428-7898 Fax: Denmark Dionex Denmark A/S Egegaardsvej 41-st 2610 Rodovre Denmark Phone: 45-36-36-90-90 45-36-36-90-99 Fax: England Dionex (UK) Ltd. 4 Albany Court Camberley Surrey, GÚ16 7QL England Phone: 44 1276 691722

44 1276 691837

Fax:

France Dionex S.A 164-166 AVENUE Joseph Kessel 78960 Voisins Le Bretonneux France Phone: 33 1 39 30 01 10 33 1 39 30 01 12 Fax: Germany Dionex GmbH Am Woertzgarten 10 D-65510 Idstein Germany Phone: 49 6126 991-0 Fax: 49 6126 991277 Italy Dionex S.r.I. Via della Maglianella, 65R 00166 Roma Italy Phone: 39 06 66 51 5052 39 06 66 51 5057 Fax: Japan Nippon Dionex K.K. DNX Shin-Osaka Bldg 6-3-14 Nishi-Nakajima Yodogawa-ku Osaka 532-0011 Japan Phone: 81 6 6885-1213 81 6 6885-1215 Fax: Korea Dionex Korea Ltd. In Sung Building 89-106 Shinjung 2-dong Yangcheon-gu Seoul, 158-849 Korea Phone: 82 2 2653-2580 Fax: 82 2 2653-2508 Switzerland Dionex (Switzerland) AG Solothurnerstr. 259 4600 Olten Switzerland Phone: 41 62 205 99 66 Fax: 41 62 205 99 60 The Netherlands Dionex B.V. Lange Bunder 5 4854 MB Bavel The Netherlands Phone: 31 161 434303 Fax. 31 161 433065

> © 2004 Dionex Corporation LPN XXXXX 10M 09/04 Printed in U.S.A.



